ABSTRACT

A photosensitive polymer composition includes (a) a polyamide having a repeating unit represented by the following general formula (I):

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wherein U represents a tetravalent organic group, V represents a bivalent organic group and p is an integer representing a number of the repeating unit; (b) a compound which generates an acid upon receiving light; and (c) a compound represented by the following general formula (II):

wherein m and n are each independently integer of 1 or 2, Rs are each independently hydrogen, alkyl group or acyl group, and R^1 and R^2 each independently represents fluoroalkyl group having 1 to 3 carbon atoms.